



5373/tat

"PATENT APPLICATION"

3/31/03
#7/EGT
(3ms)
Amdt
A

IN THE UNITED STATES PATENT AND TRADEMARK OFFICE

In re Application of

BERND LOCHEL ET AL

U.S. Serial No. 09/700,033

Filed: January 31, 2001

METHOD OF AND APPARATUS FOR
DRYING PHOTO RESIST LAYERS

Group Art Unit 1756

N. Barreca, Examiner

RECEIVED
MAR 28 2003
GROUP 1700

Alexandria, Virginia
March 20, 2003

Honorable Commissioner of Patents and Trademarks
Washington, D.C. 20231

A M E N D M E N T

Dear Sir:

This is in response to the official action mailed
September 20, 2002. In response to the outstanding office
action, please amend the application as set forth below.

03/25/2003 HADELR1 00000024 09700033
01 FC:1253 930.00 OP